

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/785,438		02/24/2004	Sang Dang Tang	108298679US1	8502	
25096	7590	11/28/2005		EXAMINER		
PERKINS	COIE LL	.P	CAO, P	CAO, PHAT X		
PATENT-SI	EA					
P.O. BOX 1	247		ART UNIT	PAPER NUMBER		
SEATTLE,	WA 981	11-1247	2814	···		
				DATE MAILED: 11/28/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

An

	Application No.	Applicant(s)			
	10/785,438	TANG, SANG DANG			
Office Action Summary	Examiner	Art Unit			
	Phat X. Cao	2814			
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING D - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION (36(a)). In no event, however, may a reply be time will apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONE	I. sely filed the mailing date of this communic (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 24 February 2004.					
2a) This action is FINAL . 2b) ☐ This	action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the					
closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11, 45	3 O.G. 213.			
Disposition of Claims					
4) ☐ Claim(s) 34-52 is/are pending in the application 4a) Of the above claim(s) is/are withdra 5) ☐ Claim(s) 34-39 and 46-52 is/are allowed. 6) ☐ Claim(s) 40,44 and 45 is/are rejected. 7) ☐ Claim(s) 41-43 is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	wn from consideration.				
Application Papers					
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) accomplicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Example 11.	epted or b) objected to by the E drawing(s) be held in abeyance. See tion is required if the drawing(s) is obj	e 37 CFR 1.85(a). ected to. See 37 CFR 1.1			
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Bureat * See the attached detailed Office action for a list	ts have been received. Is have been received in Application In the second rity documents have been received In (PCT Rule 17.2(a)).	on No ed in this National Stage)		
Attachment(s)					
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date <u>2/24/04</u>. 	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:				

Art Unit: 2814

DETAILED ACTION

1. The cancellation of claims 1-33 in Paper filed on 2/24/04 is acknowledged.

Claim Objections

- 2. Claims 46 and 52 are objected to because of the following informalities:
 - in claim 46, line 5, "comprising -" should be changed to "comprising:".
 - In claim 52, line 5, "comprising –" should be changed to "comprising:".
 - In claim 52, line 17, "the conductive line" should be changed to "the conductive bit line".

Appropriate correction is required.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

The changes made to 35 U.S.C. 102(e) by the American Inventors Protection Act of 1999 (AIPA) and the Intellectual Property and High Technology Technical Amendments Act of 2002 do not apply when the reference is a U.S. patent resulting directly or indirectly from an international application filed before November 29, 2000. Therefore, the prior art date of the reference is determined under 35 U.S.C. 102(e) prior to the amendment by the AIPA (pre-AIPA 35 U.S.C. 102(e)).

Application/Control Number: 10/785,438

Art Unit: 2814

4. Claims 40 and 44-45 are rejected under 35 U.S.C. 102(e) as being anticipated by Tang et al (US. 6,376,380).

The applied reference has a common assignee with the instant application. Based upon the earlier effective U.S. filing date of the reference, it constitutes prior art under 35 U.S.C. 102(e). This rejection under 35 U.S.C. 102(e) might be overcome either by a showing under 37 CFR 1.132 that any invention disclosed but not claimed in the reference was derived from the inventor of this application and is thus not the invention "by another," or by an appropriate showing under 37 CFR 1.131.

Regarding claim 40, Tang (Figs. 23-26) discloses a microelectronic device, comprising: a workpiece including a substrate 12, a plurality of active areas 16 in the substrate, and a dielectric layer 20 over the active areas 16, the dielectric layer 20 having an upper surface; a plurality of bit line contacts 34 (Fig. 25 and column 4, lines 30-32) in the dielectric layer 20 contacting first portions of the active areas 16; a plurality of cell plugs 60 (Fig. 26 and column 5, lines 1-5) in the dielectric layer 20 contacting second portions of the active areas 16; and a conductive, elongated bit line 44 or 50 (Fig. 23 and column 5, lines 1-5) embedded in an upper portion of the bit line contacts 34 (Fig. 25) and portions of the dielectric layer 20 between the bit line contacts 34 (see Fig. 26), wherein the bit line 44 extends between the cell plugs 60 (Fig. 26).

Regarding claim 44, Tang's Fig. 25 further discloses that the dielectric layer 20 has a top surface, and the bit line 44 has a top surface coplanar with the top surface of the dielectric layer 20.

Application/Control Number: 10/785,438 Page 4

Art Unit: 2814

Regarding claim 45, Tang's Fig. 25 also discloses that the device further comprises a shallow trench isolation structure 14 adjacent to the first portion of the active areas 16, and the conductive bit line 44 is superimposed over a portion of the shallow trench isolation structure 14 but not over the first active area 16.

Allowable Subject Matter

5. Claims 34-39 and 46-52 are allowed.

The prior art fails to disclose all the limitations recited in the base claims, including the limitation of having a dielectric spacer formed between the conductive bit line and cell plugs adjacent to the conductive bit line.

6. Claims 41-43 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The prior art of record fails to disclose all the limitations recited in the above claims, including a dielectric spacer formed between the bit line and the cell plugs.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Phat X. Cao whose telephone number is 571-272-1703. The examiner can normally be reached on M-F.

7. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on 571-272-1705. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Application/Control Number: 10/785,438

Art Unit: 2814

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

PC

November 23, 2005

PRIMARY EXAMINER

Page 5